Please amend the following abstract. The abstract is also provided on a separate sheet

located at the end of this Amendment:

ABSTRACT

The invention relates to a A method for treating an implant surface intended for

implantation into bone tissue wherein a microroughness comprising having pores and peaks

having a pore diameter of ≤ 1 µm, a pore depth of ≤ 500 nm, and a peak width, at half the pore

depth, of from 15 to 150% of the pore diameter is provided. The invention also relates to an

Also provided is an implant comprising having a surface having with the above characteristics.

2 PCL/ETP/clb